

The 5th Plasma Materials Science Hall of Fame Prize

was awarded to

Prof. Rikizo Hatakeyama, Tohoku University,

for excellent achievements in cutting-edge research on plasma processing involving graphene, carbon nanotubes, and fullerenes, and innovative research on the creation of nanoarchitectures using plasma, which includes plasma nano-biomaterials science, nanoscopic plasma processing, and the creation of functional nanocarbons.



Professor Rikizo Hatakeyama,
Tohoku University

